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<th>Heteroatom modified graphenes : electronic and electrochemical applications</th>
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Heteroatom modified graphenes: electronic and electrochemical applications

Martin Pumera*

Graphene exhibits zero band gap, very small electrical resistivity, fast heat dissipation, and fast heterogeneous electron transfer properties. These features, coupled with affordable preparation cost and high surface area, predetermine graphene materials for application in electronic and electrochemical devices. Doping graphene with electron-withdrawing or -donating heteroatoms leads to tailoring of graphene electronic and electrochemical properties. Here, we discuss doping of graphene-based materials with main group heteroatoms (s and p blocks). We will also discuss the application of such doped graphenes in electronic, sensing, and energy storage/generation devices.

1. Introduction

Graphene exhibits zero band gap and fast electron transfer at the defect sites/edges of the sheets.\(^1\)\(^2\) By doping graphene with heteroatoms, one can tailor the band gap by providing or withdrawing electrons from the graphene structure and by providing electrochemically active/inactive sites. Here, we will discuss doping of graphene with main group elements, that is, with group I A to VII A (s- and p-block) including hydrogen. We intentionally excluded transition metals (d-block elements). In addition, we will discuss the methods of preparation of doped graphenes because these methods have a strong influence on the way the heteroatom is implanted into the graphene and on its properties. We will also discuss theoretical studies; however, the main focus of the article will be on experimental studies.

2. Group I A: alkali metals

Potassium-doped graphene oxides exhibited faster electron transfer rates towards ferro/ferricyanide than did non-doped graphene oxides. Graphite oxide, prepared by the Hummers or Hofmann method, was mixed with metallic (elemental) potassium in a glove box and subjected to thermal exfoliation. The resulting materials contained \(~0.5\) at% of K and also a much higher amount of oxygen-containing groups than those of the control experiment in the absence of elemental K. The reason is that potassium is bonded in alcoholates and thus prevents these groups from vaporization. Despite a larger amount of oxygen-containing groups, the K-doped graphene oxide exhibited faster heterogeneous electron transfer than did the control sample of thermally reduced graphene oxide.\(^3\) It also showed an electrocatalytic effect towards the reduction of \(\text{NO}_2^-\) and \(\text{SO}_4^{2-}\) ions.\(^4\)

3. Group II A: alkaline earth metals

Doping graphene by the second main group (II A) to alter electronic or electrochemical properties is very rare. In a theoretical and experimental study on the electron transport properties of Ca-doped graphene, it was concluded that the theoretical results significantly differed from the measurements.\(^5\) There is certainly...
much more to do in the field of doping graphene with second main group elements, as they show strong interactions with oxygen-containing groups of graphene oxide; such interaction gains intensity with increasing atomic weight of the II A group element.

4. Group III A: the boron group

Boron is a common atom for doping graphene for electrochemical and electronic purposes. In general, boron is considered a p-type dopant. However, this is only true if the boron atom is integrated into the graphene lattice. When boron is incorporated as a $-$BH$_2$ group, the electron-withdrawing effect is not strong. There are different methods of doping graphene with boron. The synthetic methodology influences the way boron is incorporated and thus the resulting electronic and electrochemical properties. Hydroboration with BH$_3$ in tetrahydrofuran leads to $-$BH$_2$ group doped graphenes as this mechanism prohibits direct doping of the graphene lattice and it is a simple addition reaction on the C=C bond (Fig. 1). Such graphenes exhibited high electrochemical weight capacitance (Fig. 2).

Boron was doped by the thermal exfoliation/reduction of graphite oxide (which was prepared by the Staudenmaier method) in a BF$_3$ atmosphere at 800 °C. In such a case, boron was directly incorporated into the graphene lattice. Such graphene demonstrated fast heterogeneous electron transfer, faster than for N-doped graphene. Similarly, B-doped graphene exhibited higher electrical conductivity than did N-doped graphene.

Graphenes doped with increasing amounts of boron in their lattice showed inhibition of ORR with increased amounts of B as well as decreased capacitance. This is opposite to graphene doped with boron groups in the $-$BH$_2$ form. The role of B (and N) doping in increasing the capacitance of graphene was recently questioned.

B-doped graphenes exhibited higher resistance to electrode fouling during electrochemical analysis of biomarkers when compared to undoped graphene materials. In other reports, it was claimed that boron was doped by heating B$_2$O$_3$ at 1200 °C with graphene oxide. One should note that B$_2$O$_3$ sublimes (and does not decompose to B and O) at ~1500 °C. In this work, electrocatalysis towards an oxygen reduction reaction was reported. In a different study, H$_3$BO$_3$ was heated to 900 °C in the presence of graphene, doping by B and electrocatalysis of ORR were reported. In a similar manner, at this temperature, H$_3$BO$_3$ loses water and transforms into B$_2$O$_3$.

5. Group IV A: carbon group

It has been calculated that doping graphene with IV group elements (carbon group) increases its band gap to 2.13 eV for Si, while when doped with Ge or Sn, the band gap is about half of...
Doping graphene with these elements is very rare; it is certainly an interesting area for investigation. It should be mentioned that Si strongly dopes the graphene layer that is in contact with the Si wafer. However, it does not influence the electronic properties of subsequent layers.\(^\text{17}\)

6. Group V A: pnictogens

Group V A elements are, in principle, electron donors. However, similar to group III A, the electron-donating/withdrawing effect depends on the chemical bonding arrangement.\(^\text{18}\) Nitrogen doping is very widely used for tailoring the electronic and electrochemical properties of graphene. Nitrogen can be incorporated into the graphene lattice in various forms, such as quaternary nitrogen, pyridinic N, pyrrolic N, aromatic amine, hydroazone, pyrazole and pyrazoline groups; these groups can exhibit completely contrasting electronic properties, such as an electron-donating group (amine) or as an electron-withdrawing group (quaternary nitrogen), see Fig. 3. Even though the way nitrogen is incorporated into the graphene lattice significantly influences the properties of the doped graphene, it is difficult to gain full control over the chemical configuration of the doped nitrogen. Nitrogen-doped graphenes were demonstrated to act as electrocatalysts for hydrogen peroxide reduction, which is very important in biosensing applications. Nitrogen-doped graphenes showed fast heterogeneous electron transfer (HET) rates to Co(bpy)\(_3\)^{3+/2+} which is immensely important for applications in solar cells; the HET rates increased with the increased level of N doping, as indicated in Fig. 4A.\(^\text{19}\) Nitrogen-doped graphenes also exhibited higher currents for hydrogen peroxide reduction, which is of very high importance in the biosensing set-up, where H\(_2\)O\(_2\) is often an enzymatic product (Fig. 4B).\(^\text{20}\) N-doped graphenes were reported to be very powerful for ORR.\(^\text{21}\) It was suggested that quaternary nitrogen plays a major role in ORR.\(^\text{22}\) Co-doped B and N graphenes reportedly exhibit even higher electrocatalysis for ORR.\(^\text{23}\) N-doped graphene was also shown to exhibit high capacitance.\(^\text{24,25}\) It was demonstrated that such increased capacitance is due to the so-called quantum capacitance.\(^\text{26}\) N-doped graphene was also shown to be a superior metal-free counter electrode in organic dye-sensitized solar cells\(^\text{19}\) as well as a metal-free electrode for electrocatalytic water oxidation.\(^\text{27}\)

Phosphorus was doped into graphene by mixing graphene oxide with phosphoric acid and drying, which was reported to have an electrocatalytic effect in ORR.\(^\text{28}\) It is possible to simultaneously reduce GO and dope with phosphorus via refluxing it with P\(_2\)/KOH.\(^\text{29}\)

7. Group VI A: chalcogens

Oxygen is very often part of graphene structure because one of the main routes of graphene synthesis is via graphite oxide,\(^\text{30-32}\)

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**Fig. 3** Nitrogen-doped graphene containing various groups which are either electron-donating or electron-withdrawing. Some of these groups are shown in the scheme above. Note that reduction of graphene oxide with hydrazine will dope the graphene with nitrogen containing moieties which are shown in blue color. (A) Quaternary nitrogen; (B) pyridinic N; (C) pyrrolic N; (D) aromatic amine; (E) hydroazone; (F) pyrazole and (G) pyrazoline groups at the graphene fragment.

**Fig. 4** Electrochemistry at nitrogen-doped graphenes. (A) Cyclic voltammograms obtained at a scan rate of 10 mV s\(^{-1}\) for the oxidation and reduction of the Co(bpy)\(_3\)^{3+/2+} redox couple using the Pt and NGnP working electrodes, in 0.1 M LiClO\(_4\); increasing numbers at labels indicate increasing doping levels. (B) Hydrogen peroxide reduction is catalyzed at N-doped graphene. Reprinted with permission from ref. 19 and 20, respectively.
graphene oxide with consecutive reduction. Oxygen moieties on graphene are considered unwanted and major efforts are being made to remove them. The oxygen-containing groups present on the graphene surface are of a wide variety, both electron withdrawing and donating. These include hydroxyl, aldehyde, ketone, peroxide, epoxide, carbonyl, ester, lactone, etc. It is extremely challenging to selectively remove/introduce particular groups. It was demonstrated that heterogeneous electron transfer rates increase with a decrease in the amount of oxygen-containing groups. It is possible to tune the amount of oxygen-containing groups (epoxy, peroxy, and aldehyde) by electrochemical reduction and consequently tuning HET rates. The electrical conductivity of graphene oxide increases upon the removal of oxygen from the graphene structure; this is the basis for claims of the restoration of sp² C=C bonds upon removal of these groups. However, the real reason for increased conductivity is not fully known.

Sulfur-doped graphenes can be fabricated by either thermal exfoliation of graphite oxide in sulfur-containing gas (i.e., H₂S, CS₂ or SO₂) or by carbonizing graphene with organic molecules containing sulfur, i.e., styrene sulfonate or benzyl disulfide. The amount of sulfur incorporated into the graphene lattice by the method using graphite oxide and H₂S, CS₂ or SO₂ gas as precursors for thermal exfoliation/doping depends mostly on the method the graphite oxide was prepared (whether by Hummers, Hofmann, or Staudenmaier method) rather than on the type of gas (Fig. 5a).

When the amount of sulfur in the graphene lattice was increased, the electrical resistivity increased as well. During exfoliation in an atmosphere containing sulfur gas, different sulfur-containing moieties, such as –SH or –SO₃⁻, are introduced, depending on the exfoliation conditions. Increased capacitance of sulfur-doped graphenes compared to undoped ones was reported. Sulfur-doped graphenes were also shown to act as metal-free electrocatalysts for oxygen reduction (Fig. 5b–d). Graphenes co-doped with both sulfur and nitrogen also show electrocatalytic effects towards oxygen reduction. Selenium-doped graphene also exhibited electrocatalysis in ORR.

8. Group VII A: halogens

Halogen atoms exhibit both the electron-withdrawing effect due to electronegativity and the resonance donating effect due to the existence of lone pair of electrons. The electronic structure of graphene changes significantly depending on the halogen atom. Fluorinated graphene has a wide band gap of 3.1 eV, while chlorinated graphene has a much smaller band gap of 0.9 eV and brominated graphene has almost zero band gap (Fig. 6). It was found experimentally that with increasing halogen size (and decreasing electronegativity), the electrical resistivity of halogen-doped graphene decreases; this is consistent with theoretical results.

The electrochemical properties of halogen (X = Cl, Br, I) doped graphenes show the fastest heterogeneous electron transfer for Cl-doped graphene and the slowest for I-doped graphene (Fig. 7). This is consistent with the trend of decreasing electronegativity (3.16 for Cl, 2.96 for Br and 2.66 for I).
The conductivity of Br-graphene oxide.

Similarly, the fast HET was shown on F-doped graphites (electronegativity of F is 3.98), where HET increased with increased fluorination of graphite. The fluorination (which in general can be carried out with XeF$_2$, CF$_4$ (ref. 51–54) plasma, SF$_6$, MoF$_6$ (ref. 55) or fluoropolymers) leads to inhomogeneously functionalized materials with conductive network even at high fluorination levels. Cl-doped graphene showed p-doped semiconductor characteristics. For Br-doped graphene oxides, the amount of residual oxygen-containing groups was found to be the governing factor for the decreased conductivity of Br-graphene oxide.

Doping of graphene with halogen atoms can be accomplished in various ways, i.e., doping starting graphite and exfoliating it to halogenated graphene, exfoliating graphite to graphene and consequently doping it, or anything in between. One can first dope graphite (i.e., by fluorination, which is an industrial process to obtain Cl$_2$) and consequently exfoliate the resulting material. It is possible to dope graphenes during thermal exfoliation of graphite oxide in an atmosphere containing halogen gas (Cl, Br, I at 1000 °C). Alternatively, graphite oxide can first be exfoliated by ultrasonication and by introducing Cl$_2$ gas, which leads to a reaction with GO thereby doping it with Cl. A Cl$_2$ plasma treatment of graphene will dope graphene with Cl$_2$ at 10 mTorr. The p-doped graphene with Cl exhibited increased electrical conductivity with a short plasma treatment (10 s), after which the conductivity decreased with increasing plasma treatment (30 s) (Fig. 8).

9. Hydrogen

Note that for the purpose of general discussion, it is useful to treat hydrogen as part of group VII A because it has more characteristics common with halogens than it does with alkali metals. The hydrogenation of graphene opens the zero band gap and completely changes its electronic properties. It was theoretically calculated that the band gap of fully hydrogenated graphene (such a material is called graphane) is 3.7 eV. One can change the band-gap by tuning the level of hydrogenation. Single-layer graphene hydrogenated in low pressure (0.1 mbar) H$_2$ plasma exhibited ~ two orders of magnitude lower conductivity than did pristine graphene (Fig. 9). Similarly, CVD graphene/graphane transition led to a change from metallic to semiconducting properties of the material. Hydrogenation of up to 10% of H coverage led to a two orders-of-magnitude increase in the sheet resistance of graphene, a one order-of-magnitude decrease in carrier mobility, and a metallic to semiconducting behavior after hydrogenation. The electrochemical properties of hydrogenated graphenes depend on the degree of hydrogenation. At low hydrogenation levels (~3.5 at% of H), heterogeneous electron transfer to ferro/ferricyanide is slower than that in graphene. However, with increasing hydrogenation, HET rate dramatically increases. This is likely due to a large increase in the number of defects in graphene sheets induced by hydrogenation, which are beneficial to HET. Hydrogenation can be in general carried out by low pressure H$_2$ plasma hydrogenation, high pressure (hundreds of atm) hydrogenation or wet chemistry hydrogenation, which involves either the Birch reaction in liquid ammonia or hydrogenation with nascent hydrogen. Hydrogenated graphene has been proven to be highly useful for the electrochemical detection of biomarkers. However, it was inefficient.
10. Conclusions & outlook

The doping of graphene with main group elements can strongly influence its electronic and electrochemical properties by introducing n- or p-doping. Doped graphenes exhibit industrially important electronic and electrochemical properties, such as increased capacitance, electrocatalysis of oxygen reduction reactions, and electrocatalytic reduction of biomarkers. We have shown that with the exception of I A, II A, VII A, and hydrogen elements, the classical semiconductor industry division of the boron group as p- (hole) doping and the nitrogen and chalcogen group as n- (electron) doping is not generally applicable to graphene. This is because doping elements are very often not fully integrated into the lattice and they are added onto it forming groups that can be of various types, either electron withdrawing or donating. It must be understood that in many research reports, the exact nature of the bonding arrangement of the dopants, which is crucial for understanding the resulting properties, is not accessed. Having said that, even when the bonding arrangement is investigated, one should realize that in typical graphene doped with III, V, or VI main group elements, several types of bonding arrangements typically coexist. It remains a challenge in this field to create procedures that will lead to the doping of graphene with a single type of dopant bonding arrangement.

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